#### 200 mA Magnetized Beam for MEIC Electron Cooler

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# Outline

- MEIC Magnetized Electron Beam Cooling Requirements
- Source Pros and Cons
- Gun Options:
  - I. CW RF guns, warm and cold
  - II. Thermionic gun
  - III. Photogun
- Magnetized Beam
- Summary

# Bunched Magnetized Electron Gun Requirements

Bunch length	100 ps (3 cm)
Repetition rate	476 MHz
Bunch charge	420 pC
Peak current	4.2 A
Average current	200 mA
Emitting area	6 mm φ
Transverse normalized emittance	10s microns
Solenoid field at cathode	2 kG

### **Source Pros and Cons**

- Warm CW RF gun: thermionic emitter or photocathode, the promise of high bunch charge, but long low-energy tail, managing heat load for CW operation (AES and LANL examples)
- CW SRF gun: huge potential, but also huge technical challenges including applied mag field (Rossendorf and BNL)
- RF-pulsed grid thermionic gun: simple, long lifetime, but also long pulse and worst emittance (TRIUMF and BINP's NovoFEL)
- DC high voltage photogun: good emittance, delicate photocathodes, high bunch charge demands high bias voltage (JLab and Cornell)

# **Source Dependencies**

- Thermal Emittance: Intrinsic property of a cathode. Depends on work function, surface roughness, laser wavelength, temperature.
- Achievable Current: QE, laser wavelength, laser power, laser damage, heating, emitter size, temperature.
- Bunch Charge: laser peak power, repetition rate, active cathode area, bunch length.
- Cathode Lifetime: ion back bombardment, dark current, contamination by residual gas, evaporation, beam loss, halo beam.

What will applied magnetic field do?

# Warm CW RF gun options

# **Example 1:** Advanced Energy Systems (AES), Inc., NCRF gun (A. Todd, ERL11):

RF frequency	1 GHz
Bunch length	1 <b>– 5 ps</b>
Bunch charge	0.2 nC
Normalized emittance	20 microns
Bean energy (after pre-booster)	1 MeV
Micropulse length	1 – 8 µs
Micropulse repetition rate	10 Hz



Pulsed gun – Could it be used as CW?

#### **Example 2:** LANL/AES 2.5-cell Photocathode NCRF gun:

RF frequency	700 MHz
Bunch repetition rate	35 MHz
Average current	100 mA
Bunch length	9 ps
Bunch charge	1 – 3 nC
Normalized emittance	7 microns
Bean energy	2.5 MeV
Energy spread	<1.3%
Ohmic losses	780–820 kW
E cathode	10 MV/m



#### D.C. Nguyen et al., NIM A 528, 71 (2004)

# **CW SRF Gun Options**

#### Example 1: Rossendorf (BESSY-DESY-FZD):A. Burrill, EIC14

	Injector 0	Injector 1	Injector 2	
Goal	Beam Demonstrator	Brightness R&D Injector	High-current injector	
Electron energy		≥ 1.5 MeV		
RF frequency	1.3 GHz			
Design peak field	≤ 50 MV/m			
Operation launch field		≥ 10 MV/m		
Bunch charge	≤ 77 pC			
Repetition rate	30 kHz	54 MHz / 25 Hz	1.3 GHz	
Cathode material	Pb	CsK <sub>2</sub> Sb	CsK <sub>2</sub> Sb	
Cathode QE	10 <sup>-4</sup> at 258 nm	2-10% at 532 nm	2-10% at 532 nm	
Laser wavelength	258 nm	532 nm	532 nm	
Laser pulse energy	0.15 μJ	1.8 nJ	1.8 nJ	
Laser pulse shape	Gaussian	Gaussian/Flat-top	Gaussian/Flat-top	
Laser pulse length	2.5 ps FWHM	≤ 20 ps	20 ps	
Average current	0.5 μΑ	≤ 10 mA / 0.1 mA	100 mA	



#### **Example 2:** BNL SRF guns program (S. Belomestnykh, EIC14):

Two SRF photoemission guns are under active development:

- I. 704 MHz ½-cell elliptical gun to deliver high bunch charge and high average current beams for R&D ERL
- II. 112 MHz QWR gun is designed to produce high bunch charges, but low average beam currents for Coherent electron Cooling (CeC) Proof-of-Principle experiment

#### Preparing for first beam test

Two other SRF guns under development:

- I. 1.3 GHz SRF plug gun for GaAs photocathodes
- II. 84.5 MHz SRF gun for eRHIC CeC injector

# **Thermionic Gun Options**

**Example 1:** TRIUMF e-Linac for photo-fission of actinide target materials to produce exotic isotopes:

- BaO: 6 mm diameter, 775°C
- Grid at 650 MHz
- Gun HV: 300 kV
- Average current: 25 mA
- Bunch charge: 38 pC



 Normalized emittance: 30 microns. Emittance is dominated by electric field distortion caused by grid.

# **Example 2:** Thermionic Gun and 1.5 MeV Injector of BINP's NovoFEL. B.A. Knyazev *et al.*, Meas. Sci. Tech. **21**, 054017

(2010):





Gun HV	300 kV
Maximum peak current	1.8 A
Maximum average current	30 – 45 mA
Maximum bunch repetition rate	22.5 MHz
Bunch length	1.3 ns
Bunch charge	1.5 – 2 nC
Normalized emittance	10 microns

# **Photogun Options**

# **Example 1:** JLab 200 kV Inverted dc Gun with K<sub>2</sub>CsSb photocathode:

- Average beam current: 10 mA
- Laser: 532 nm, dc
- Lifetime: very long (weeks)
- Thermal emittance: 0.7 microns/mm(rms)





Mammei et al., Phys. Rev. ST AB 16, 033401 (2013)

#### Example 2: JLab 350/500 kV Inverted dc Gun:

	200 kV Gun	350/500 kV Gun
Chamber	14" φ	18" ф
Cathode	2.5" T-shaped	6" φ Ball
Cathode Gap	6.3 cm	6.3 cm
Inverted Ceramic	4" long	7" long
HV Cable	R28	R30
HV Supply	Spellman 225 kV, 30 mA	Glassman 600 kV, 5 mA
Maximum Gradient	4 MV/M	7 (10) MV/m





Achieved 350 kV with no FE, next:
Keep pushing to reach 500 kV
Run beam with K<sub>2</sub>CsSb photocathode

# **Example 3:** Cornell dc Gun with K<sub>2</sub>CsSb photocathode: Dunham et al., Appl. Phys. Lett. 102, 034105 (2013)

- Gun HV: currently operating at 350 kV (designed 500-600 kV)
- Average beam current: 65 mA for 9 hours (lifetime 2.6 days)
- Bunch charge: 50 pC
- Bunch length: 10 ps, 1.3 GHz
- Normalized emittance: <0.5 microns</p>





# Magnetized Beam and Emittance Compensation

Magnetized Cathode:

To produce magnetized (angular-momentumdominated) electron beam to ensure zero angular momentum inside coolingsolenoid section)



- II. Injector Solenoids:
  - To compensate space-charge emittance growth
- III. Will be easier to implement with compact gun (inverted photogun or thermionic gun)

# Summary

I. Thermionic gun would be our first choice (less maintenance but may need complicated injector):

#### > TRIUMF/BINP Gun with Inverted Ceramic

II. For better emittance, a dc HV photogun is good option:

JLab 350/500 kV Inverted Gun and JLab multi-alkai photocathode (Na<sub>2</sub>KSb or K<sub>2</sub>CsSb)

III. If one gun cannot provide 200 mA, then use two or three guns and combine beams using RF combiner or dipole magnet

# LDRD: 200 mA Magnetized Beam

- I. Use JLab 350/500 kV Inverted Gun and K<sub>2</sub>CsSb photocathode
- II. Design and build Cathode Solenoid
- III. Generate magnetized beam
- IV. Measure beam magnetization:
  - i. Measure beam emittance vs. beam size
  - ii. Measure directly using slit and screen
  - iii. Measure after round to flat transformation
- V. Study transportation of magnetized beam and round to flat beam transformation
- VI. Measure magnetized photocathode lifetime at high currents
- VII. Repeat with 100 kV thermionic gun loaned to TRIUMF Slide 17

#### **Backup Slides**

#### **Magnetized Electron Cooling**

#### **Busch's Theorem**

- On entering or exiting solenoid, beam acquires a kick that makes beam to rotate
- Busch's Theorem: Canonical angular momentums is conserved,  $mr^2 \theta + \frac{e}{2\pi} \Phi = P_{\theta} = Const.$

$$P_{\theta} = \frac{1}{2} e B_z \sigma_e^2$$

Magnetic emittance:

$$\varepsilon_{mag} = \frac{eB_z \sigma_e^2}{2m_e c}$$

 $\epsilon_{mag} [microns] \sim 30 \; B[kG] \; \sigma_e [mm]^2$ 

### **Magnetized Cooling**



### Why: Magnetized beam?

I. Magnetic field limits transverse motion of electrons; cooling rate is determined by longitudinal velocity spread:

$$\lambda = \tau^{-1} \approx \frac{\rho}{v - v_{e\parallel}}$$

II. Cooling rate for non-magnetized beam:

$$\lambda = \tau^{-1} \approx \frac{\rho}{v_{e\perp}}$$

### **Cooling Solenoid**

- I. Cooling solenoid: 30 m long and 2 T field
- II. Electron and ion are moving at same speed in cooling section (solenoid)
- III. Inside cooling solenoid, electron beam is <u>calm</u>: not to have any angular motion

IV. Cooling solenoid must have high parallelism of magnetic field lines:

$$\frac{\Delta B_{\perp}}{B_z} < 10^{-5}(?)$$

### Cooling Rate: Dependencies on Electron Beam Properties

- I. Proportional to average beam current (does not depend on peak current)
- II. Independent of ion beam intensity
- III. Proportional to cooler length
- IV. Magnetized cooling is less dependent on electron beam transverse emittance
- V. Cooling rates with magnetized electron beam are ultimately determined by electron longitudinal energy spread only
- VI. Non-magnetized beam depends on transverse electron velocity (a weak field may be used for focusing – i.e., FNAL dc cooler, 100 G)
- VII. Bunched electron (from SRF gun) cooling planned at BNL without any magnetization, shield magnetic field < 0.2 mG

# Electron – ion Recombination Suppression

- I. Suppresses ion-electron recombination in cooling section if loss of luminosity is not negligible
  - No suppression is planned at BNL. Future upgrade to use undulator field, 3 G and 8 cm period
  - For magnetized beam, cyclotron motion, due to large transverse temperature in cooling section, suppresses recombination

#### **Paraxial Beam Envelope Equation**

$$\sigma'' + \frac{\gamma'}{\beta^2 \gamma} \sigma' + \left(\frac{eB_z}{2mc\beta\gamma}\right)^2 \sigma - \frac{2I}{I_0\beta^3\gamma^3} \frac{1}{\sigma} - \left(\frac{P_\theta}{mc\beta\gamma}\right)^2 \frac{1}{\sigma^3} - \left(\frac{\varepsilon_n}{\beta\gamma}\right)^2 \frac{1}{\sigma^3} = 0$$
Acceleration
Injector Solenoids
(for space-charge
emittance growth
compensation)
Space Charge
Cathode Solenoid
Cathode Emission
$$P_\theta = P_{Cath\_Sol} - P_{Cool\_Sol} \approx 0$$

$$P_{Cath\_Sol} = \frac{1}{2} eB_z R^2 \quad B_z = 2 \text{ kG}$$

$$P_{Cool\_Sol} = \frac{1}{2} e B_z \sigma_e^2 \quad \mathsf{B}_z = 20 \text{ kG}$$

#### MEIC Polarized Electron Source

## **MEIC Polarized Source**



- Pockels cell switching time at CEBAF today ~70 us. Planned for Moller Exp. ~10 us
- Bunch charge 72 x larger than typical CEBAF, 20 x greater than G0 Expect to use a gun operating at higher voltage
- 68.05 MHz pulse repetition rate not be a problem for gun, maybe for LINACs
- We are not considering simultaneous beam delivery to fixed target halls, using typical CEBAF beam
- Message: MEIC polarized source requirements do not pose significant challenges

### **Source Parameter Comparison**

No K <sub>2</sub> CsSb	Yes	Yes	Yes
K <sub>2</sub> CsSb			
2	100	100	1000
0.77	25	0.5002	337
1300	40	1999	3
-	-	156 ns	1 ms
-	-	50	5
77	640	960	4800
38.5	6.4	9.6	4.8
0.3	0.5	1	1
500	32	12	6
100	25	0.015	0.072
	2 0.77 1300 - - 77 38.5 0.3 500 100	2       100         0.77       25         1300       40         -       -         -       -         77       640         38.5       6.4         0.3       0.5         500       32         100       25	$\begin{array}{c ccccccccccccccccccccccccccccccccccc$

Proposed

\* Unpolarized: Bulk GaAs (Cs,F), K<sub>2</sub>CsSb, Na<sub>2</sub>KSb, ... Polarized: GaAs/GaAsP (Cs,F).

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# **Addressing MEIC Bunch Charge**

#### 20 to 72 times larger than CEBAF

- I. Larger Laser Size (reduces space-charge emittance growth and suppresses surface charge limit)
- II. Higher Gun Voltage:
  - Reduce space-charge emittance growth, maintain small transverse beam profile and short bunch-length; clean beam transport
  - Compact, less-complicated injector
- III. To accelerate large bunch charge in CEBAF: use RF feedforward system for C100 cryomodules

### JLab 500 kV Inverted Gun



Spherical electrode